

I hereby certify that this correspondence is being filed via
EFS-Web with the United States Patent and Trademark Office
on November 17, 2006.

TOWNSEND and TOWNSEND and CREW LLP

By: /Nina L. McNeill/
Nina L. McNeill

PATENT
Attorney Docket No.: AM2119/T2130
AMAT No.: AM2119/T21300
TTC No.: 16301M-021300US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Karl Littau et al.

Application No.: 08/893,917

Filed: July 11, 1997

For: REMOTE PLASMA CLEANING
SOURCE HAVING REDUCED
REACTIVITY WITH A SUBSTRATE
PROCESSING CHAMBER

Customer No.: 57385

Confirmation No. 8435

Examiner: Rudy Zervigon

Technology Center/Art Unit: 1763

RESPONSE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed May 17, 2006, please enter the following
amendments and remarks:

A **Listing of Claims** begins on page 2 of this paper.

Remarks begin on page 5 of this paper.